

ABSTRACT OF THE DISCLOSURE

A positive photosensitive composition comprises: (A) an acid generator capable of generating an acid upon irradiation with one of an actinic ray and a radiation; and (B) a resin having a monocyclic or polycyclic alicyclic hydrocarbon structure and capable of decomposing by the action of an acid to increase the solubility in an alkali developer, wherein the acid generator (A) comprises at least two compounds of a sulfonyl salt compound not having an aromatic ring, a triarylsulfonyl salt compound, and a compound having a phenacylsulfonyl salt structure.

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